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## A theoretical study of atmospheric pollutant NO<sub>2</sub> on as-doped monolayer WS<sub>2</sub> based on DFT method

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### ABSTRACT

For the relevant properties of pristine and doped (Si, P, Se, Te, As) monolayer WS<sub>2</sub> before and after the adsorption of CO, CO<sub>2</sub>, N<sub>2</sub>, NO, NO<sub>2</sub> and O<sub>2</sub>, density functional theory (DFT) calculations are made. Calculation results reveal that the monolayer WS<sub>2</sub> doped with P and As atoms can be substrate materials for NO and NO<sub>2</sub> gas sensors. However, after the subsequent CDD and ELF calculations, it is found that P-doped monolayer WS<sub>2</sub> adsorbs NO and NO<sub>2</sub> in a chemical way, while As-doped monolayer WS<sub>2</sub> adsorbs NO and NO<sub>2</sub> in a physical way. Also, the charge transfer between As-doped monolayer WS<sub>2</sub> and NO is relatively small and not easily detected. Besides, As-doped monolayer WS<sub>2</sub> system exhibits greater differences in optical properties (the imaginary part of reflectivity and dielectric function) before and after the adsorption of NO<sub>2</sub> gas than before and after adsorption of NO gas. These differences in optical properties assist sensor devices in making gas adsorption-related judgments. Through the analysis of the recovery time, DOS and PDOS, As-doped monolayer WS<sub>2</sub> is also verified to be a promising NO<sub>2</sub> sensing material, whose recovery time is calculated to be as short as 0.169 ms at 300 K.

### 1. Introduction

Gases are diverse and ubiquitous. Usually, different gases have different properties and sources. For instance, some gases are indicators of life and health, while others are highly dangerous or even deadly. One of the most common samples of harmful gases is NO<sub>2</sub>, which can be widely seen in both chemical synthesis and industrial production. It is reported that when the concentration of NO<sub>2</sub> in our surrounding environment exceeds 1 ppm, severe respiratory diseases can be caused [1]. Toxic gases like NO<sub>2</sub> not only harm the human body, but also give rise to severe environmental issues, for instance, acid rain and photochemical smog [2,3]. Thereby, gas sensing is needed in various fields represented by environmental protection and safety monitoring of industrial processes [4]. Besides, detection of toxic gases is also crucial for the maintenance of air quality, the control of vehicle emissions, medical diagnosis and biohazard detection [5–8]. The leakage of these gases must be closely monitored.

Metal oxide gas sensors have once been widely concerned, but they were found having the defects of instability and limited working

conditions [9]. Therefore, we need to search for new materials that can be used for the detection of these gases [10]. In order to detect gas molecules as efficiently as possible, it is essential that the material has a large surface-to-volume ratio and the ability of providing binding force which is sufficient enough for gas adsorption [11,12]. Two-dimensional (2D) materials, like graphene [13], just meet the above requirements. They have a high surface-to-volume ratio, a wide range of chemical compositions, and a unique thickness dependence [14,15]; all these characteristics make 2D materials ideal for applications in the field of gas sensing. Researches also reveal that 2D materials exhibit excellent properties and performance in nano electronic devices [16,17], and that 2D materials-based gas sensors have higher sensitivity, selectivity, response and recovery rate, and stability [18]. Consequently, 2D materials have been extensively studied for the past few years.

It is worth mentioning that, in particular, compared with graphene and other 2D materials, 2D transition metal dichalcogenides (TMDs) display obvious advantages in performance whether they are used as substrate materials for electronic, optical or electrochemical sensors [19–23]. Latest researches have concentrated on two TMDs: MoS<sub>2</sub>

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[24–27] and WS<sub>2</sub> [28,29]. Both theoretical and experimental studies have shown that MoS<sub>2</sub> nanosheets are sensitive detectors for NO, NO<sub>2</sub>, NH<sub>3</sub> and triethylamine gases [24,26,30–34]; but the gas sensing performance of WS<sub>2</sub> nanosheets has been seldom studied. In fact, as a member of TMDs materials, WS<sub>2</sub> has a variety of unique characteristics of sensing materials [35,36]. In 2015, the charge transfer of gas molecules adsorbed on 2D WS<sub>2</sub> was theoretically investigated [37]. What they have found is that most gas molecules (such as H<sub>2</sub>, O<sub>2</sub>, H<sub>2</sub>O and NH<sub>3</sub>) can be adsorbed on the surface of WS<sub>2</sub> monolayer in a physical way, which indicates that WS<sub>2</sub> is indeed promising as a gas sensing material.

In this study, the adsorption of NO<sub>2</sub> and five other common gases (CO, CO<sub>2</sub>, N<sub>2</sub>, NO, O<sub>2</sub>) on 2D WS<sub>2</sub> is systematically investigated through first principal calculations, so as to explore the possibility of 2D WS<sub>2</sub> as a substrate material for NO<sub>2</sub> sensors. Considering that the pristine 2D sensing material has poor adsorption capacity for the target gas, that is, it cannot effectively capture gas molecules [38]; in order to modify the binding forces between the material and the gas molecules, and to enhance the sensing capabilities of materials, doping is widely applied throughout the research of 2D materials [39,40]. For instance, in gas sensing, Pd-doped WS<sub>2</sub> exhibits obvious merits over the pristine WS<sub>2</sub> [7, 41]. And since P, Si, Se, Te and As atoms have a covalent radius close to that of S atoms, the S atom can be easily replaced by them and a stable covalent structure at the doping site can be formed [42–45]. Therefore, we investigate the adsorption effect of P, Si, Se, Te and As doped WS<sub>2</sub> on NO<sub>2</sub> and the above five gases. In addition, we also examine the extent to which the sensing performance of the 2D WS<sub>2</sub> is affected when exposed to the atmosphere. This work provides a comprehensive insight into the application of 2D WS<sub>2</sub> for NO<sub>2</sub> gas sensing.

## 2. Methodology

First-principle calculations are carried out substrated on the framework of DFT [46–48]. The exchange correlation interaction is processed via the generalized gradient approximation (GGA) within the Perdew-Burke-Ernzerh (PBE) functional [49,50]. To better describe the interlayer van der Waals (vdW) interactions, the dispersion corrected density functional theory (DFT-D) [51] with Grimme [52] methods is applied. All of the atomic positions are optimized until the force and the energy tolerances are below 0.002 Ha/Å and 10<sup>-5</sup> eV, respectively. The Brillouin zone integration is sampled for a 3 × 3 WS<sub>2</sub> supercell using 5 × 5 × 1 and 9 × 9 × 1 k-grid meshes so as to calculate the geometry optimization and electronic properties, respectively;

The adsorption energy ( $E_a$ ) is obtained through the following formula to intuitively reflect the adsorption strength between WS<sub>2</sub> and gas molecules:

$$E_a = E_{WS_2+gas} - E_{WS_2} - E_{gas} \quad (1)$$

where  $E_{WS_2+gas}$ ,  $E_{WS_2}$  and  $E_{gas}$  stand for the overall energy of the system composed of monolayer WS<sub>2</sub> and the adsorbate, the energy of monolayer WS<sub>2</sub>, and the energy of the isolated gas molecule, respectively. Besides, to explore the electron redistribution in these systems, the charge density difference (CDD) is calculated via:

$$\Delta\rho = \rho_{WS_2+gas} - \rho_{WS_2} - \rho_{gas} \quad (2)$$

where  $\rho_{WS_2+gas}$ ,  $\rho_{WS_2}$  and  $\rho_{gas}$  stand for the charge density of the system composed of monolayer WS<sub>2</sub> and the adsorbate, the charge density of monolayer WS<sub>2</sub>, and the charge density of the isolated gas molecule, respectively. To precisely estimate the interaction mechanism between monolayer WS<sub>2</sub> and gas molecules, the electron localization function (ELF) of some systems is also considered.

## 3. Results and discussion

To begin with, calculation results of the geometry optimization are

examined: the lattice constants  $a$  and  $b$  of the WS<sub>2</sub> unit cell are both equal to 3.242 Å, which are in accordance with the values obtained by other research groups [53].

### 3.1. Structural characteristics of WS<sub>2</sub> monolayer

Fig. 1 demonstrates that monolayer WS<sub>2</sub> is composed of three layers of atoms. For the S atoms in the uppermost and lowermost layers, they are each bonded to three W atoms; while for the W atoms in the interlayer, they are each bonded to six S atoms. As for possible adsorption positions on monolayer WS<sub>2</sub>, there are three possibilities, which are P1 (on top of a S atom), P2 (on top of a W atom), and P3 (on top of the center of the W–S–W–S–W–S hexatomic ring).

### 3.2. Adsorption of gas molecules on WS<sub>2</sub> monolayer

To probe the sensing behavior of monolayer WS<sub>2</sub> for gas molecules (CO, CO<sub>2</sub>, N<sub>2</sub>, NO, NO<sub>2</sub>, O<sub>2</sub>), we calculate different structural and electrical characteristic parameters of different adsorption systems. The initial distance between monolayer WS<sub>2</sub> and the gas molecule is set to 3.00 Å. Among these parameters,  $d$  represents the shortest distance between the atoms of monolayer WS<sub>2</sub> and the adsorbed gas molecule, while  $r$  is the related covalent radii. The charge transfer ( $\Delta Q$ ) is calculated by means of Mulliken population analysis. The negative value of  $\Delta Q$  indicates that the charge transfers from monolayer WS<sub>2</sub> to the gas molecule. More detailed calculation results are given in Table 1.

As shown in Table 1, except for the NO and NO<sub>2</sub> adsorption systems, no charge transfer exists between monolayer WS<sub>2</sub> and the gas in the other four adsorption systems. However, the  $\Delta Q$  of the NO and NO<sub>2</sub> adsorption systems are merely 0.04 e and 0.03 e respectively, which is almost negligible. To make matters worse, the  $d$  in each adsorption system is also greater than the initial value (3.00 Å). Even in the NO/WS<sub>2</sub> system with the smallest  $d$ , the difference between  $d$  and  $r$  is as much as 1.43 Å. The above facts all indicate that the interaction between the pristine WS<sub>2</sub> monolayer and the gas may not be strong.

In order to verify our guess, we selectively calculate the CDDs and ELF of the NO and NO<sub>2</sub> adsorption systems. The reason for choosing these two systems is that in these two systems, there is at least certain charge transfer between the substrate and the gas. As expected, as displayed in Fig. 2, from the CDDs of the two systems (Fig. 2(a, b, d, e)), we can see that there is almost no charge accumulation and depletion between monolayer WS<sub>2</sub> and the gas. Besides, the ELFs (Fig. 2(c, f)) also

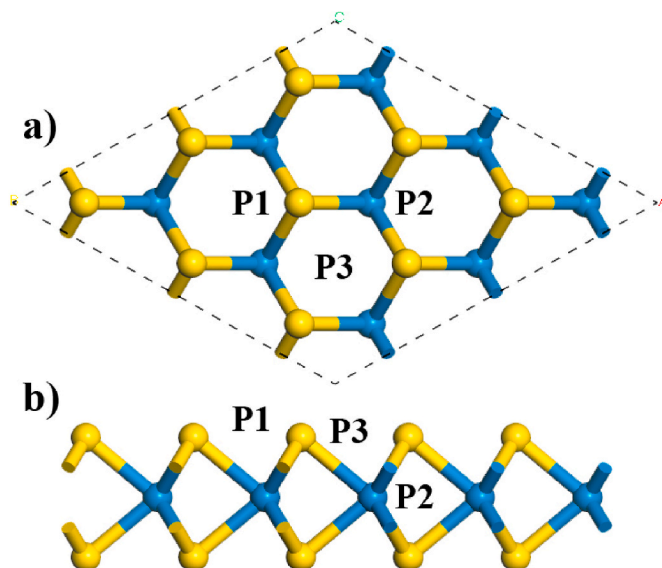


Fig. 1. Views of the optimized WS<sub>2</sub> monolayer (a: top view; b: side view).

**Table 1**  
Detailed adsorption parameters of different gases on monolayer WS<sub>2</sub>.

WS <sub>2</sub>	<i>E<sub>a</sub></i> (eV)	$\Delta Q$ (e)	<i>d</i> (Å)	<i>r</i> (Å)
CO	-0.21	0.00	3.46	1.80(C-S)
CO <sub>2</sub>	-0.26	0.00	3.33	1.80(C-S)
N <sub>2</sub>	-0.21	0.00	3.58	1.77(N-S)
NO	-0.23	0.04	3.20	1.77(N-S)
NO <sub>2</sub>	-0.33	-0.03	3.50	1.77(N-S)
O <sub>2</sub>	-0.20	0.00	3.55	1.77(O-S)

demonstrate that there is almost no electron localization between monolayer WS<sub>2</sub> and the gas. The undoped monolayer WS<sub>2</sub> does not possess strong gas adsorption capacity, thus it does not have the ability to be a qualified gas sensing material. We can only turn to investigate the gas adsorption performance of the doped monolayer WS<sub>2</sub>.

### 3.3. Adsorption of gas molecules on doped WS<sub>2</sub> monolayer

In this section, we calculate and analyze the adsorption capacity of P-, Si-, Se-, Te- and As-doped monolayer WS<sub>2</sub> for gas molecules (CO, CO<sub>2</sub>, N<sub>2</sub>, NO, NO<sub>2</sub>, O<sub>2</sub>).

Firstly, we need to determine whether the structure of each doped substrate is stable. This is a prerequisite for all adsorption calculations. As we observed, the bond lengths of W-S bonds around dopants hardly change, which tells us that doping only changes lengths of W-X bonds. At this point, we can conclude that the adsorption calculations based on each doped substrate are scientific and reliable.

The adsorption parameters of P-, Si-, Se-, Te- and As-doped monolayer WS<sub>2</sub> are listed in Tables S1–4 and Table 2, respectively.

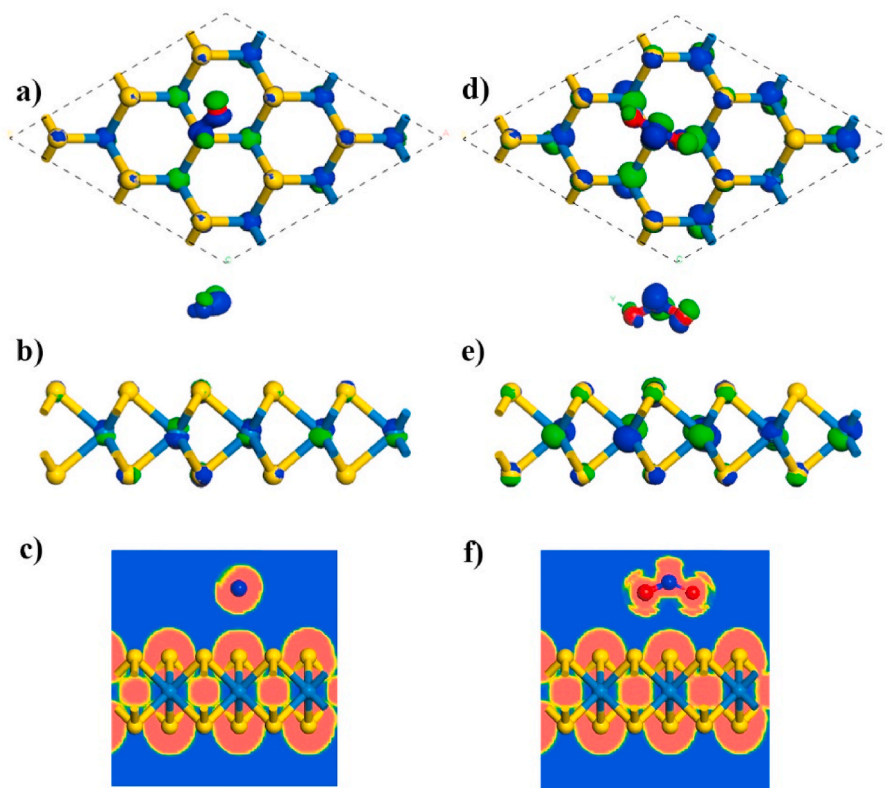
From the perspective of *d*, the adsorption performance of P, Si and As doped monolayer WS<sub>2</sub> for many gases is significantly improved compared with that of pristine monolayer WS<sub>2</sub>, while the Se and Te doped monolayer WS<sub>2</sub> are on the contrary. Taking NO<sub>2</sub> adsorption as an

example, in the systems doped with P, doped with Si, and doped with As, *d* decreases from 3.50 Å in the undoped system to 1.91 Å, 1.89 Å and 2.33 Å, respectively; in the Se and Te doped systems, *d* increases to 3.61 Å and 3.68 Å, respectively. From the perspective of *E<sub>a</sub>*, the *E<sub>a</sub>* of the NO<sub>2</sub>/WS<sub>2</sub> system is -0.33 eV. In the systems doped with P, Si, and As, *E<sub>a</sub>* grows to -0.88 eV, -2.26 eV and -0.55 eV respectively; while in the Se-doped and Te-doped NO<sub>2</sub> adsorption systems, both *E<sub>a</sub>* reduces to -0.28 eV.

Since our goal is to find a 2D material which has the ability to be a qualified NO<sub>2</sub> sensing material, and monolayer WS<sub>2</sub> doped with Se or Te has no advantage in gas adsorption capacity even compared with the undoped monolayer WS<sub>2</sub>. Hence, it is obviously not necessary to continue in-depth calculation and analysis for them. Yet at the same time, we also note that the improvement of gas adsorption performance of monolayer WS<sub>2</sub> by Si doping seems to be too comprehensive and significant: when the system doped with Si, in addition to CO<sub>2</sub>, when the other five gases (CO, N<sub>2</sub>, O<sub>2</sub>, NO and NO<sub>2</sub>) are adsorbed on Si-doped monolayer WS<sub>2</sub>, the *d* (1.82 Å, 1.80 Å, 1.67 Å, 1.89 Å and 1.73 Å) between them and the substrate are less than the corresponding *r* (1.95 Å, 1.92 Å, 1.92 Å, 1.92 Å and 1.92 Å). Whether the selectivity is poor or *d* is too small, it is a disaster for gas sensing materials. A poor selectivity signifies that the gas-sensitive material cannot accurately capture the target gas, and a too small *d* indicates that the gas capture process of the

**Table 2**  
Detailed adsorption parameters of different gases on monolayer As-WS<sub>2</sub>.

As-WS <sub>2</sub>	<i>E<sub>a</sub></i> (eV)	$\Delta Q$ (e)	<i>d</i> (Å)	<i>r</i> (Å)
CO	-0.20	0.00	3.59	2.02(C-As)
CO <sub>2</sub>	-0.23	-0.01	3.53	2.02(C-As)
N <sub>2</sub>	-0.20	0	3.80	1.99(N-As)
NO	-0.62	0.04	2.45	1.99(N-As)
NO <sub>2</sub>	-0.55	-0.12	2.33	1.99(N-As)
O <sub>2</sub>	-0.19	0.00	3.56	1.99(O-As)



**Fig. 2.** CDDs of the adsorption systems composed of monolayer WS<sub>2</sub> and NO (a, b) and NO<sub>2</sub> (d, e) (isosurface value: 0.04 e/Å<sup>3</sup>) and ELFs of the adsorption systems composed of monolayer WS<sub>2</sub> and NO (c) and NO<sub>2</sub> (f).

gas-sensitive material may not be reversible. In consequence, there is also no need to further explore the possibility of Si-doped monolayer WS<sub>2</sub> as a gas-sensitive material.

Fortunately, P-doping and As-doping enhance the gas adsorption performance of monolayer WS<sub>2</sub> selectively: only when NO and NO<sub>2</sub> are adsorbed on the P-doped or As-doped substrate, are the  $d$  (1.90 Å, 1.91 Å; 2.45 Å, 2.33 Å) and  $r$  (1.84 Å, 1.84 Å; 1.99 Å, 1.99 Å) between gas molecules and the substrate relatively close. Like other gases, such as CO<sub>2</sub>,  $d$  is 1.51 Å larger than  $r$  in both P-doped and As-doped systems, which is not much smaller than the difference of 1.53 Å between  $d$  and  $r$  in undoped systems. In addition, in both systems,  $d$  is not smaller than  $r$  as in Si-WS<sub>2</sub> systems. Both P-doped and As-doped monolayer WS<sub>2</sub> have the potential to serve as NO<sub>2</sub> sensing materials. Based on the results obtained, we need to perform CDD and ELF calculations on the adsorption system composed of P-doped monolayer WS<sub>2</sub> and NO or NO<sub>2</sub>, and the adsorption system composed of As-doped monolayer WS<sub>2</sub> and NO or NO<sub>2</sub>, respectively, to reveal the mechanism of interaction between NO or NO<sub>2</sub> and these two doped substrates.

To begin with, the CDD calculation results of each adsorption system are analyzed. From Fig. 3(a–h), in general, we can observe that under the premise of the same isosurface value (all set to 0.04 e/Å<sup>3</sup>), compared with As-doped monolayer WS<sub>2</sub> (Fig. 3(e–h)), in the systems which consist of P-doped monolayer WS<sub>2</sub> and two gases (Fig. 3(a–d)), the blue and green regions representing charge accumulation and dissipation are distributed more densely, which is exactly the manifestation of the  $\Delta Q$  difference between the substrate and the gas in the P-doped and As-doped systems: according to Tables S2 and 2, in the adsorption systems composed of P-WS<sub>2</sub> and NO and NO<sub>2</sub> respectively, the  $\Delta Q$  between the gas and the substrate is 0.18 e and 0.25 e respectively, which is much greater than the 0.04 e and 0.12 e in As-WS<sub>2</sub> adsorption systems.

Secondly, from the ELF diagram of each adsorption system (Fig. 4(a–d)), in the interlayer regions between NO and P-WS<sub>2</sub> and between NO<sub>2</sub> and P-WS<sub>2</sub> (Fig. 4(a and b)), the electrons are highly localized, and the red regions representing ELF values of 1 overlap; while in the systems composed of As-WS<sub>2</sub>, NO and NO<sub>2</sub> respectively (Fig. 4(c and d)), there are still blue regions representing ELF values of 0 between the substrate and the gas. For ELF, its value ranges from 0 to 1, representing the degree of electron localization from low to high; in the meantime, the degree of electron localization between the substrate and the gas from low to high represents the electron sharing between the substrate and the gas from less to more. It is thereby obvious that there is electron sharing between P-doped monolayer WS<sub>2</sub> and NO and NO<sub>2</sub>, and the approach for the doped substrate to adsorb the two gases is chemical adsorption; however, no overlap of electron localization exists between As-doped monolayer WS<sub>2</sub> and NO and NO<sub>2</sub>. The As-doped substrate adsorbs both gases by physical adsorption.

Since the P-doped monolayer WS<sub>2</sub> adsorbs NO and NO<sub>2</sub> by chemical adsorption, similar to Si doped monolayer WS<sub>2</sub>, the process of capturing NO and NO<sub>2</sub> by P-doped monolayer WS<sub>2</sub> is not reversible; and since the

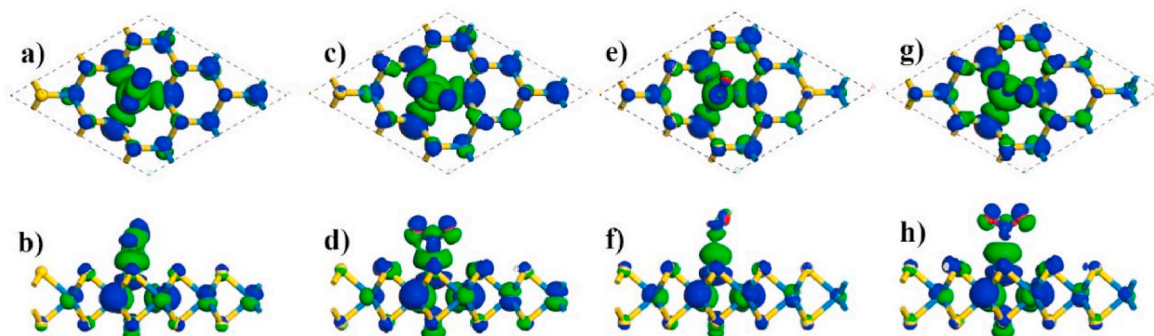


Fig. 3. CDDs of the adsorption systems composed of P-doped monolayer WS<sub>2</sub> and NO (a, b) and NO<sub>2</sub> (c, d) and the adsorption systems composed of As-doped monolayer WS<sub>2</sub> and NO (e, f) and NO<sub>2</sub> (g, h) (isosurface value: 0.04 e/Å<sup>3</sup>).

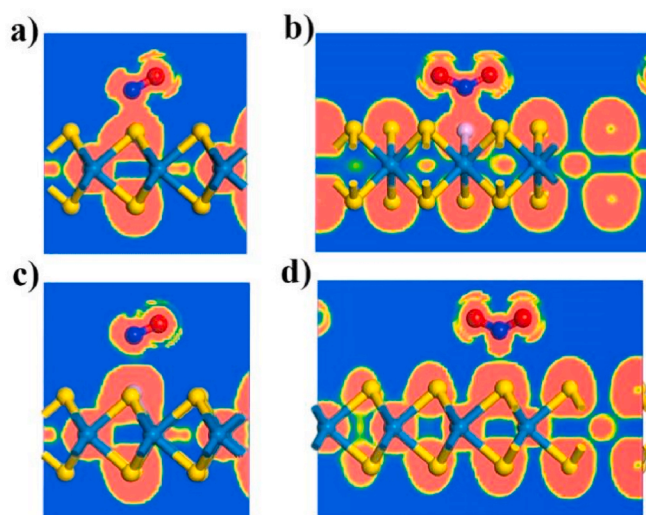


Fig. 4. ELFs of the adsorption systems composed of P-doped monolayer WS<sub>2</sub> and NO (a) and NO<sub>2</sub> (b) and the adsorption systems composed of As-doped monolayer WS<sub>2</sub> and NO (c) and NO<sub>2</sub> (d).

As-doped monolayer WS<sub>2</sub> adsorbs NO and NO<sub>2</sub> in a physical way, thus by increasing the ambient temperature or applying an external electric field, without destroying the structure of the As-doped monolayer WS<sub>2</sub>, the NO and NO<sub>2</sub> adsorbed by As-doped monolayer WS<sub>2</sub> can be restored to a free state, and in other words, the process of capturing NO and NO<sub>2</sub> by As-doped monolayer WS<sub>2</sub> is reversible.

And because, in the adsorption systems which consist of As-WS<sub>2</sub>, NO and NO<sub>2</sub>, the  $\Delta Q$  is 0.04 e and 0.12 e, respectively. Apparently, compared with NO<sub>2</sub>,  $\Delta Q$  between NO and As-WS<sub>2</sub> is too small. Although As-doped monolayer WS<sub>2</sub> adsorbs NO and NO<sub>2</sub> by physical adsorption, it must be considered that too small  $\Delta Q$  leads to too small electrical signal change before and after the sensing material adsorbs gas, that is so say, as a result, the As-doped monolayer WS<sub>2</sub> has little discrimination before and after the adsorption of NO. Therefore, As-doped monolayer WS<sub>2</sub> is a 2D material that is more qualified as a NO<sub>2</sub>-sensitive material, which is in line with our goal.

### 3.4. Optical properties

The behavior of adsorption will change the properties of materials, which is vividly reflected in optical properties [54,55]. By observing the optical properties of As-doped adsorption systems, the gas adsorption can be studied more clearly and the feasibility of the practical application of NO<sub>2</sub> gas sensor based on monolayer As-WS<sub>2</sub> can be further elaborated.

The complex refractive index represents the difference between

electromagnetic waves propagating in vacuum and other materials, which is represented by real and imaginary parts, respectively [56]:

$$N = n + ik \quad (3)$$

Other relevant optical properties can also be calculated from the real and imaginary parts of the complex refractive index. Among them, the complex dielectric function is a vital optical parameter, which stands for the process of electron transition. Its real part and imaginary parts have different meanings, which correspond to the process of absorbing and releasing photons, respectively [57]. Their expressions are [58,59]:

$$\varepsilon = \varepsilon_1 + \varepsilon_2 \quad (4)$$

$$\varepsilon_1 = n^2 - k^2 \quad (5)$$

$$\varepsilon_2 = 2nk \quad (6)$$

Due to the correlation between optical properties, reflectivity (especially in the simple case of perpendicular incidence to the plane) can also be obtained from the complex refractive index [59]:

$$R = \left| \frac{1 - N}{1 + N} \right|^2 = \frac{(n-1)^2 + k^2}{(n+1)^2 + k^2} \quad (7)$$

Fig. 5(a) demonstrates the imaginary part of the dielectric function before and after As-doped monolayer WS<sub>2</sub> adsorbs NO<sub>2</sub> gas. In the entire

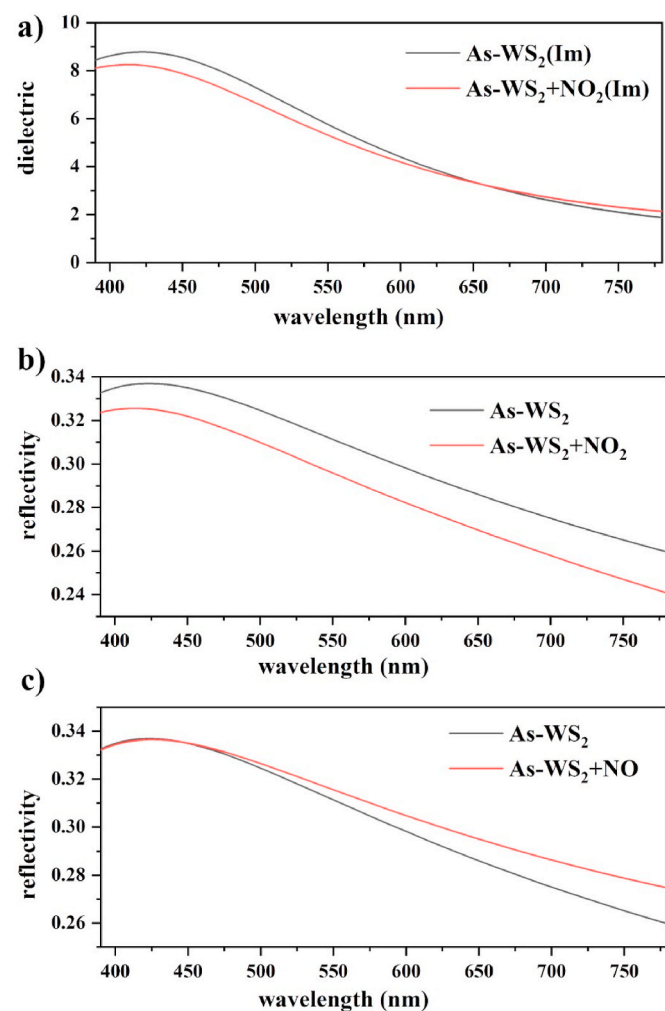


Fig. 5. The imaginary part of the dielectric function of NO<sub>2</sub>/As-doped monolayer WS<sub>2</sub> system (a) and the reflectivity of NO<sub>2</sub>/As-doped monolayer WS<sub>2</sub> system (b) and NO/As-doped monolayer WS<sub>2</sub> system (c).

visible region, both systems have function values greater than zero. The difference is that in the region between 390 and 670 nm, the function value of the system before adsorption of NO<sub>2</sub> is higher than that of the system after adsorption of NO<sub>2</sub>. When the wavelength of light exceeds 670 nm, the opposite happens. This means that in the visible region, the As-WS<sub>2</sub> system has a higher utilization rate of visible light than the adsorption system composed of As-doped monolayer WS<sub>2</sub> and NO<sub>2</sub> [52].

Also, from Fig. 5(b and c), with the increase of the wavelength of light, the reflectivity of the two systems first reaches an insignificant peak at about 470 nm and then decreases all the time. For the adsorption system composed of As-doped monolayer WS<sub>2</sub> and NO<sub>2</sub>, its reflectivity is always lower than that of the monolayer As-WS<sub>2</sub> system itself in the entire visible region (Fig. 5(b)); and for the adsorption system composed of As-doped monolayer WS<sub>2</sub> and NO, the variation of reflectivity before and after monolayer As-WS<sub>2</sub> adsorbs NO is not obvious (Fig. 5(c)), especially in the interval from 390 to 500 nm, the two are almost identical. This allows us to understand that when monolayer As-WS<sub>2</sub> is used as a sensing material for NO<sub>2</sub>, such a difference in reflectivity can make its state more conveniently judged.

Through the above analysis, conclusion is reached that the difference in optical properties before and after monolayer As-WS<sub>2</sub> adsorbs NO<sub>2</sub> gas can be safely used to help determine whether NO<sub>2</sub> gas is absorbed by monolayer As-WS<sub>2</sub>, so that the accuracy of NO<sub>2</sub> gas sensors based on monolayer As-WS<sub>2</sub> can be improved under certain circumstances.

### 3.5. Recovery time

Recovery time is another vital parameter to measure whether the sensing material has practicality or not. Here, the recovery time of the adsorption system composed of As-doped monolayer WS<sub>2</sub> and NO<sub>2</sub> is calculated. The transition state theory enlightens us that the recovery time can be estimated via the following equation [60]:

$$\tau = w^{-1} e^{-\frac{E^*}{kT}} \quad (8)$$

where  $T$  is the temperature,  $k$  corresponds to the Boltzmann constant,  $w$  represents the trial frequency ( $10^{13} \text{ s}^{-1}$ ) [61], and  $E^*$  stands for the desorption energy barrier, which is numerically equal to  $Ea$  [62].

It can be seen from this formula that with temperature increasing, the recovery time will become smaller and smaller. Therefore, the increase in temperature can increase the possibility of repeated use of the sensor. Several temperature values, namely  $T = 200 \text{ K}$ ,  $300 \text{ K}$  and  $1000 \text{ K}$ , are selected for the calculation of the recovery time of As-doped monolayer WS<sub>2</sub> after it adsorbs NO<sub>2</sub> gas, respectively. At  $200 \text{ K}$ , the recovery time of the NO<sub>2</sub> adsorption system is  $6.927 \text{ s}$ ; at  $300 \text{ K}$ , it falls to  $0.169 \text{ ms}$ ; and at  $1000 \text{ K}$ , it drops to only  $34.37 \text{ ns}$ . It can be seen from the different recovery times corresponding to different temperatures that the increase in temperature makes it easier for NO<sub>2</sub> to leave the surface of the substrate. Not only that, it can be discovered that even at a very low atmospheric temperature ( $200 \text{ K}$ ), the desorption time is still an ideal value. As-doped monolayer WS<sub>2</sub> is thereby further verified as an ideal NO<sub>2</sub> sensing material.

### 3.6. DOS and PDOS

Last but not least, in order to fully illustrate the high sensitivity of monolayer As-WS<sub>2</sub> to NO<sub>2</sub> molecules and the persuasiveness of previous results, the DOS and PDOS of the system composed of As-doped monolayer WS<sub>2</sub> and NO<sub>2</sub> are calculated.

The DOS curves of the As-WS<sub>2</sub> system before and after the adsorption of NO<sub>2</sub> are compared (Fig. 6(a and b)). It can be seen from Fig. 6(a) that the curve before and after adsorption has shifted, and new absorption peaks (at approximately  $1 \text{ eV}$ ) also appear. If the DOS curve before and after adsorption changes significantly (mainly reflected in the overall displacement of the curve or the appearance of new peaks), then the substrate has a high sensitivity to gas molecules.

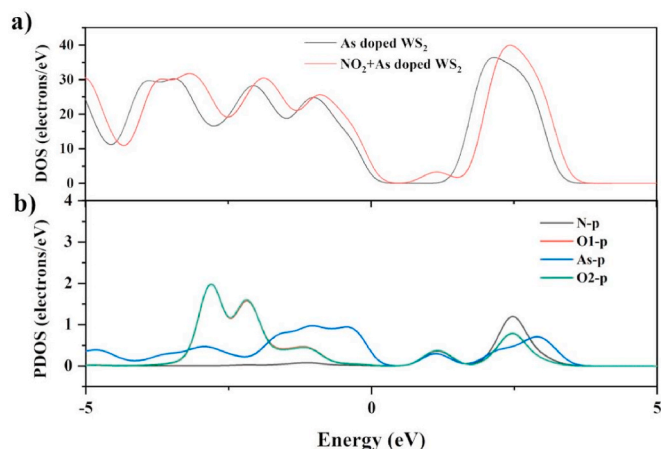


Fig. 6. DOS (a) and PDOS (b) of the adsorption systems composed of As-doped monolayer WS<sub>2</sub> and NO<sub>2</sub>.

Then, since there is only p-type hybridization between As and NO<sub>2</sub>, as shown in Fig. 6(b) only the PDOS of the p-orbitals of the dopant atom As and the N, O1 and O2 atoms of the adsorbed gas NO<sub>2</sub> are calculated. It can be observed that from -5 eV to 5 eV, the PDOS curves of the p-orbitals of these four atoms do have similar variation trends. If the same trends on the PDOS curves of the dopant atom and the atom closest to it in the adsorbed gas molecule are observed at a specific energy, then orbital hybridization exists between the two atoms. This phenomenon can be explained as a strong interaction between the substrate and the gas.

Through above analysis, As-doped monolayer WS<sub>2</sub> can indeed be considered as having sufficient sensitivity to NO<sub>2</sub>. In a nutshell, As-WS<sub>2</sub> monolayer is a strong candidate for NO<sub>2</sub> sensing materials.

#### 4. Conclusion

In this paper, through DFT calculation and comparison of the changes of  $\Delta Q$ , CDD, ELF, optical properties, recovery time, DOS and PDOS and other related properties before and after the pristine and doped (Si, P, Se, Te, As) monolayer WS<sub>2</sub> adsorb gases (CO, CO<sub>2</sub>, N<sub>2</sub>, NO, NO<sub>2</sub>, O<sub>2</sub>), the possibility of As-doped monolayer WS<sub>2</sub> as a NO<sub>2</sub>-sensitive material is explored and determined. Through the comparison among adsorption distances, both P-WS<sub>2</sub> and As-WS<sub>2</sub> are shown to have the possibility of being NO and NO<sub>2</sub> sensors. Through the calculation of CDD and ELF, it is found that P-WS<sub>2</sub> adsorbs both NO and NO<sub>2</sub> in a chemical way. Between the remaining two adsorption systems, NO<sub>2</sub>/As-WS<sub>2</sub> system is superior to NO/As-WS<sub>2</sub> system in charge transfer and reflectivity. Also, the calculation of recovery time helps us understand that the recovery time of NO<sub>2</sub>/As-WS<sub>2</sub> system is still within an acceptable range even at a very low atmospheric temperature. PDOS and DOS analysis also verify that monolayer As-WS<sub>2</sub> is a promising substrate material for NO<sub>2</sub> sensors.

#### Credit author statement

Shuhan Hou: Conceptualization, Methodology, Software, Writing – original draft preparation, Reviewing and Editing. Zhaokun Wang: Methodology, Data curation, Software, Visualization, Validation, Reviewing and Editing. Huiru Yang: Methodology, Software, Investigation. Jing Jiang: Data curation, Investigation. Chenshan Gao: Methodology, Software, Investigation. Yufei Liu: Visualization, Investigation. Xiaosheng Tang: Visualization, Investigation. Huaiyu Ye: Conceptualization.

#### Declaration of competing interest

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence the work reported in this paper.

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#### Appendix A. Supplementary data

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